

Crystal Engineering and Ferroelectricity at the Nanoscale in Epitaxial 1D Manganese Oxide on Silicon

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Abstract

Ferroelectric oxides have attracted much attention due to their wide range of applications, especially in electronic devices such as nonvolatile memories and tunnel junctions. As a result, the monolithic integration of these materials into silicon technology and its nanostructuring to develop alternative cost-effective processes are among the central points in current technology. In this work, we used a chemical route to obtain nanowire thin films of a novel $\text{Sr}_{1+\delta}\text{Mn}_8\text{O}_{16}$ (SMO)

hollandite-type manganese oxide on silicon. Scanning transmission electron microscopy combined with crystallographic computing reveals a crystal structure comprising hollandite and pyrolusite units sharing the edges of their MnO_6 octahedra, resulting in three types of tunnels arranged along the c axis, where ordering of the Sr atoms produces a natural symmetry breaking. The novel structure gives rise to a ferroelectricity and piezoelectricity, as revealed by local Direct Piezoelectric Force Microscopy measurements, which confirmed the ferroelectric nature of SMO nanowire thin films at room temperature and showed a piezoelectric coefficient d_{33} value of 22 ± 6 pC/N. Moreover, we proved that flexible vertical SMO nanowires can be harvested and converted into electric output energy through the piezoelectric effect, showing an excellent deformability and high interface recombination. This work indicates the possibility of engineering the integration of 1D manganese oxides on silicon, a step which precedes the production of microelectronic devices.

Introduction.

Complex oxides nanomaterials with ferroelectric, piezoelectric and multiferroic properties are pivotal to design devices such as sensors, micro energy harvesters or storage and magnetoelectric devices^[1-4]. Moreover, to exploit their functionalities into future devices, the integration of these functional oxides into conventional semiconductor substrates in thin film form is essential^[5-7]. A present-day example is the growth of a ferroelectric doped hafnium oxide directly on silicon^[8], which could allow for polarization-driven memories. Other recent studies have reported a direct and bottom-up integration of a new family of epitaxial 1D single crystalline hollandite oxides on silicon substrates using chemical solution deposition (CSD) techniques^[9]. The method relies on the thermal devitrification and crystallization of the silica native layer on the silicon surface into polycrystalline α -quartz, assisted by strontium alkaline earth cation (i.e. Sr^{2+} or Ba^{2+})^[10,11]. The resulting α -quartz/Si interface act as a template to stabilize the crystallization and growth of 1D single crystalline hollandite nanowires^[9].

Hollandites have the general composition of $\text{A}_x\text{M}_8\text{O}_{16}$, being A an alkaline earth cation and M a transition metal cation, and a crystal structure comprising double chains (zigzag chains) formed by edge-sharing MO_6 octahedra. Such double chains are corner-shared and form a M_8O_{16} framework

with tunnels^[12]. Hollandites are under constant development, as shown by recent synthesis and design of novel structures with an extensive range of properties^[13–19]. However, most hollandite oxides are only available as powder bulk or single crystal, limiting their practical application. The aforementioned bottom-up CSD synthesis on silicon overcomes these limitations^[9] and offer the possibility to modify the chemical composition of hollandite nanowires and yield different physical properties^[20–22] or even to stabilize novel crystallographic structures, such as the 1D $\text{Sr}_{1+\delta}\text{Mn}_8\text{O}_{16}$ (SMO) hollandite like structure^[9]. In this work, we will show that using this chemical route one can grow large-scale 1D single crystalline and epitaxial SMO hollandite nanowire thin film directly on silicon. We will demonstrate that it is possible to construct a 3D structural model of the novel SMO hollandite consisting of a columnar mixture of hollandite and pyrolusite units by combining atomic-resolution scanning transmission electron microscopy images and computing programs existing in the *FullProf Suite* (*BondStr*, *Mol_tpcr*, *GLOpSAnn*) and *CrysFML08* (*Groups*, *Similar*)^[23]. The 3D structural model reveals a spontaneous symmetry breaking due to the ordering of Sr atoms within the available tunnels that could explain the origin of the non-centrosymmetric character of the SMO, giving rise to ferroelectricity and piezoelectricity. For the later we have used Direct Piezoelectric Force Microscopy (DPFM), which is a powerful methodology recently developed by the authors that allows to directly measure the local piezoelectric effect in thin films using an atomic force microscope (AFM)^[24,25]. DPFM measurements confirmed the ferroelectric nature at the microscale of this novel non-centrosymmetric tetragonal structure and showed a d_{33} value of 22 ± 6 pC/N. In addition, we have also proved that this ferroelectric oxide can be used for energy harvesting applications. We present a first piezoelectric nanogenerator prototype based on vertical ultra-long SMO hollandites nanowires grown on a silicon substrate with an excellent deformability and high interface recombination and more importantly, they are lead free oxide

materials composed of exclusively Sr and Mn cations that are the 12th and 9th most abundant metals in the Earth's crust.

Results and discussion

Synthesis, structural and chemical characterization of $\text{Sr}_{1+\delta}\text{Mn}_8\text{O}_{16}$ hollandite-like oxide nanowire films on silicon

SMO nanowire thin films on silicon were prepared by spin coating strontium rich solutions based on our previous development of ultra-long hollandite oxides nanowires^[9]. Here, we applied a thermal treatment in air atmosphere at high temperatures (up to 750 °C) during 2 hours of the spin coated precursor's solutions containing strontium alkaline earth cations (see more details in the experimental section). At this temperature, strontium alkaline earth cations promoted the formation of a polycrystalline quartz layer at the silicon interface as previously observed^[9,10] that finally stabilize the nucleation and crystalline growth of planar textured SMO nanowire flat films. Figure S1 shows a detailed tilted field emission gun scanning electron microscopy (FEG-SEM) image of the SMO nanowire film on silicon together with a cross-sectional high-angle annular dark field image (HAADF) scanning transmission electron microscopy (STEM) image of grown SMO nanowire film where the brighter rods correspond to the epitaxial SMO nanowires. The SMO nanowires of 1 μm length and 50 nm diameter are perfectly percolated with most of their longitudinal axis lying onto the polycrystalline α -quartz interlayer establishing a thin (50 nm thick) and flat film (roughness average of 4.4 nm) (see figure S1 b and c). A general schematic of the SMO nanowire film growth process together with FEG-SEM images acquired at intermediate growth steps are shown in Figure S2. At initial stages, i.e. at 700 °C (see Figure S2b), the SMO nanowires start to nucleate and grow, reaching an optimal crystallization after 2 hours at 750 °C

where a continuous nanowire film is formed. Above this optimal growth temperature, i.e. at 800 °C, the SMO nanowire film is totally embedded within the quartz matrix. Temperature-resolved synchrotron grazing incidence 2D X-ray diffraction analysis allowed to observe the *in-situ* crystallization of epitaxial SMO nanowires thin films on silicon. The experiment was performed in the same conditions used at the chemical laboratory i.e. under air with a ramp temperature of 3 °C min⁻¹ until 800 °C. Temperature-resolved synchrotron X-ray diffraction experiments (see Figure S3) confirmed that a homogeneous crystallization of SMO started at 700 °C without phase changes during the crystal growth. In a previous paper^[9], we analyzed the electron diffraction patterns of the SMO crystalline nanowires that we attributed to a kind of SMO hollandite-type superstructure^[26]. The electron diffraction patterns did not present ordered diffuse scattering or satellites indicative of a modulated structure. The calculated unit cell of the nanowires, called hereafter T-cell, corresponds to a tetragonal body centred cell with approximate lattice parameters $a_T \approx 25.2 \text{ \AA}$, $c_T \approx 5.7 \text{ \AA}$. At that moment, we had no electron diffraction pattern, or direct images, along the c_T -axis direction. The absence of this important structural information prevented any possibility to precisely reconstruct the atomic structure. Moreover, the amount, size and texture of SMO nanowire thin films is totally inadequate to resolve the complete atomic structure by the current techniques (X-ray diffraction, including synchrotron radiation, or neutron diffraction).

In the present work, we show the first atomic-resolution STEM images obtained with the electron beam along $[001]_{\text{SMO}}$, in which we are able to determine locally the chemical nature of the atomic columns. Combining high-resolution STEM imaging and computing programs existing in the *FullProf Suite*^[23], we were able to construct the 3D structural model of this new structure. Figure 1a and 1b show a HAADF and a simultaneously acquired annular bright field (ABF) image along the $[001]$ zone axis of a SMO nanowire, respectively. In the HAADF imaging mode the intensity of the image scales roughly with the square of the atomic number Z , which allows us to

clearly distinguish between Sr and Mn atomic columns. On the other hand, the ABF imaging mode allows for visualizing the oxygen sublattice as well, and therefore complements the Z-contrast image. These two images unveil a structure consisting of a columnar combination of hollandite and pyrolusite units sharing the edges of their MnO_6 octahedra where the total number of Mn-atoms in the T-cell is 96 (see Figure 1c and Table S1 with the atomic positions of the model). While the pyrolusite tunnels remain empty, the hollandite and new tunnels generated in this structure are occupied by the Sr atoms. A comprehensive explanation of the methodology and reasoning employed for unraveling the structure of the SMO nanowires can be found **in the paragraphs below and** in the supporting information.

We also analyzed the interfacial relationship between the polycrystalline quartz templating layer and the textured SMO nanowire film by atomically resolved STEM. Figure 1d shows a HAADF-STEM image of the interface between a single α -quartz crystal and a single SMO nanowire along the longitudinal nanowire axis, i.e. $[001]_{\text{SMO}}$ crystallographic direction. The fast Fourier transform (FFT) images reveal an in-plane epitaxial relationship between the SMO nanowire and quartz crystal given by $(660)_{\text{SMO}} [001] // (101)_{\alpha\text{-quartz}} [010]$ (see Figure 1e and f.). Notice that different spatial orientations of the quartz crystallites are possible therefore, the resulting SMO nanowires exhibit the same epitaxial relation but with diverse directions.

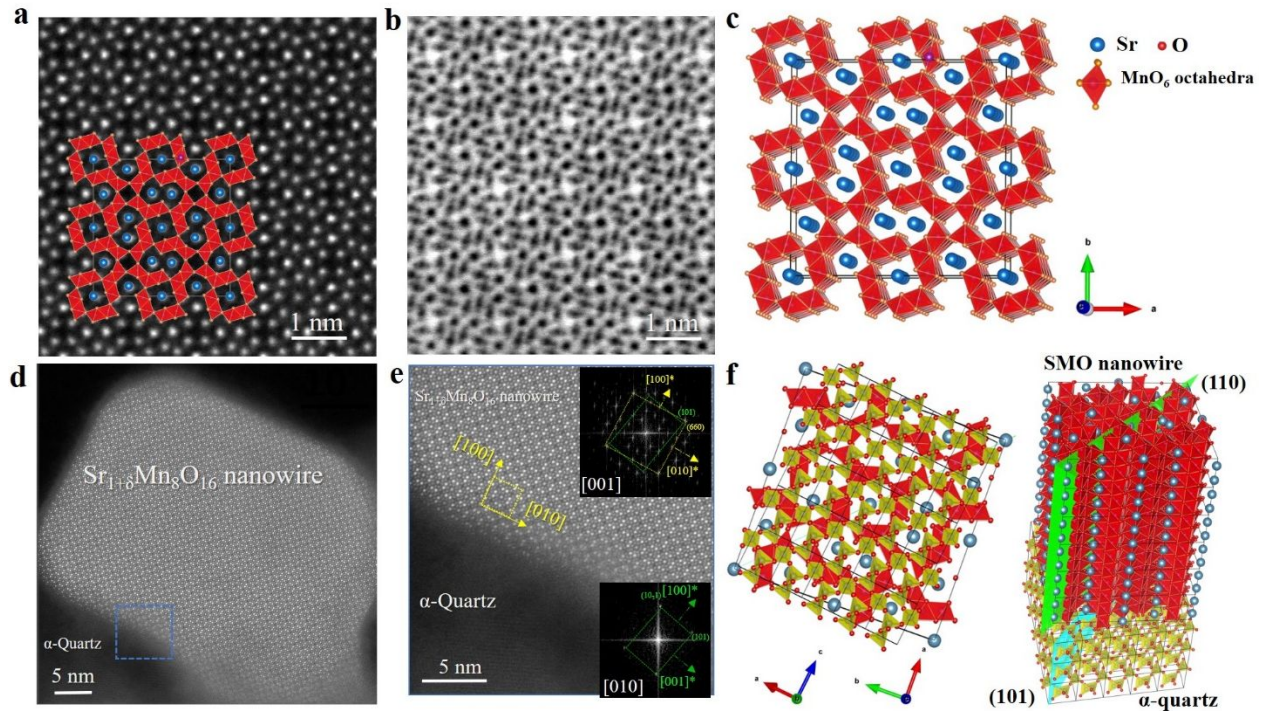


Figure 1. Structural characterization of epitaxial SMO nanowire film on silicon. (a and b) Atomically resolved HAADF and ABF-STEM images along the [001] zone axis of a single crystal SMO, respectively. The schematic atomic model is included in the (a) image. (c) Structural model proposed for a single SMO nanowire. Atomic positions are described in table S1 in the supporting information. (d) High resolution HAADF image of the SMO nanowire and quartz interlayer. (e) HAADF image of a single SMO nanowire with α -quartz interface. The insets show the FFT images that indicates the epitaxial relationship between both phases i.e. (660) SMO [001] // (101) α -quartz [010]. (f) Schematics of the atomic arrangement at the interface for the orientation relationship observed for SMO. In green the (110) plane of SMO nanowire parallel to the (101) plane of α -quartz highlighted in light blue.

Interestingly, Ph. Boullay *et al.*, described a structure in the Ba-Mn-O system^[27] that, in its [001] projected plane, is similar to what we observe for the pure Sr-Mn-O compound. We have used the information provided in this article to help the construction of an initial structural model adequate to our case. The average structure in $\text{Ba}_{6-x}\text{Mn}_{24}\text{O}_{48}$ was described approximately in the $I4/m$ space group with unit cell parameters $a_B = 18.173(2)$ Å, $c_B = 2.836(1)$ Å. However, their electron diffraction patterns indicate a more complex situation corresponding to a modulated composite structure with two different c-axes. Conversely, the diffraction patterns for the SMO structure do not present satellites or prominent diffuse scattering (see figure S4). The doubling of the c-axis

with respect to the Ba-compound is well established in the electron diffraction patterns of the novel SMO structure (see figure S5). From the $I4/m$ tetragonal cell ($\mathbf{a}_B, \mathbf{b}_B, \mathbf{c}_B$) proposed in^[27], one can obtain the T-cell of SMO nanowires acquired with electron diffraction by applying the transformation: $\mathbf{a}_T = \mathbf{a}_B + \mathbf{b}_B$, $\mathbf{b}_T = -\mathbf{a}_B + \mathbf{b}_B$ and $\mathbf{c}_T = 2\mathbf{c}_B$. Therefore, one can deduce, using the program *Similar* that allows the generation of subgroups of a superstructure obtained from the transformation of symmetry operators in the new superstructure basis, that the non-centrosymmetric $I4$ subgroup is more appropriate for describing the SMO structure. This is in comparison to the other possibility, which is the centrosymmetric $I4/m$ (see atomic positions and explanations about the modelling procedure in table S1 and the corresponding notes). This non-centrosymmetric character of the SMO structure can be attributed to an ordering of Sr atoms within the structural tunnels that we call tunnels C (see figure 2). Indeed, a full occupation by the strontium in tunnels C is not possible because there are many Sr-Sr distances equal to half c-axis ($\approx 2.87 \text{ \AA}$) which is too short and electrostatically unfavourable. Moreover, the asymmetric unit in the non-centrosymmetric group $I4$ ($\mathbf{a}_T, \mathbf{b}_T, \mathbf{c}_T$) contains 7 Sr, 12 Mn and 24 O independent atoms and only some Sr-atoms are in special positions (see Table S1). Considering a full occupation, the composition would correspond to the formula $\text{Sr}_5\text{Mn}_{12}\text{O}_{24}$. However, this composition is too high compared to the experimental relative cation composition obtained by means of EDX, this is $\text{Sr}_{0.11(2)}\text{Mn}_{0.64(9)}$, that in terms of hollandite formula becomes approximately $\text{Sr}_{1.4}\text{Mn}_8$ (see Figure S5). As a consequence, we have removed three Sr atom sites in $I4$ ($\mathbf{a}_T, \mathbf{b}_T, \mathbf{c}_T$) that do not change the pattern of Sr observed in the high-resolution HAADF images. Therefore, the composition becomes $\text{Sr}_{1.8}\text{Mn}_8\text{O}_{16}$, which is similar to the composition measured by EDX if we allow a partial occupation in the hollandite tunnels. By removing these atoms, automatically we obtain a non-centrosymmetric structure because the presence of an inversion centre implies the presence of a mirror plane duplicating the Sr-atoms within the tunnels. Therefore, only the ordered Sr-atoms

located in the tunnels C of the SMO structure break the centre of symmetry of the global structure. The rest of the Mn-O framework keeps the original inversion centre. In order to experimentally prove this hypothesis we have synthesized both, a (i) pure Ba hollandite oxide nanowire thin film that in our case exhibited the well known monoclinic structure ($\text{Ba}_{1.2}\text{Mn}_8\text{O}_{16}$, BMO) with cell parameters $a = 10.052(1) \text{ \AA}$, $b = 2.8579(2) \text{ \AA}$, $c = 9.7627(10)$, and $\beta = 89.96^{[28]}$ (see Figure S6) and (ii) a Ba hollandite oxide nanowire thin film doped with 50% of Sr, $(\text{BaSr})_{1+\delta}\text{Mn}_8\text{O}_{16}$ (BSMO), which disclosed the novel tetragonal structure above described in SMO nanowires system (see Figure S7). Remarkably, atomic-resolution electron energy loss spectroscopy (EELS) chemical mapping of the Mn, Ba, and Sr elements along the c axis of BSMO crystal structure showed unexpected cationic ordering within the novel tetragonal structure (see Figure 2 and Figure S7). Indeed, Ba atoms occupy all the hollandite tunnel (H) and prevent Sr^{2+} ions to reside in these sites of the unit cell. Conversely, in the cationic positions corresponding to the C tunnels, one can observe that Ba and Sr share these sites therefore increasing the disorder in this position. This phenomenon is non-compatible with the $I4$ non-centrosymmetric structure due to the presence, on average, of a mirror plane within the tunnels that might fill partially the C tunnels with strong columnar disorder. As a result, the assembling of Sr^{2+} and Ba^{2+} cations within the tunneled structure is extremely important for the final functionality of the hollandite oxide, hindering, the ferroelectricity of BSMO nanowires as further described in the following section.

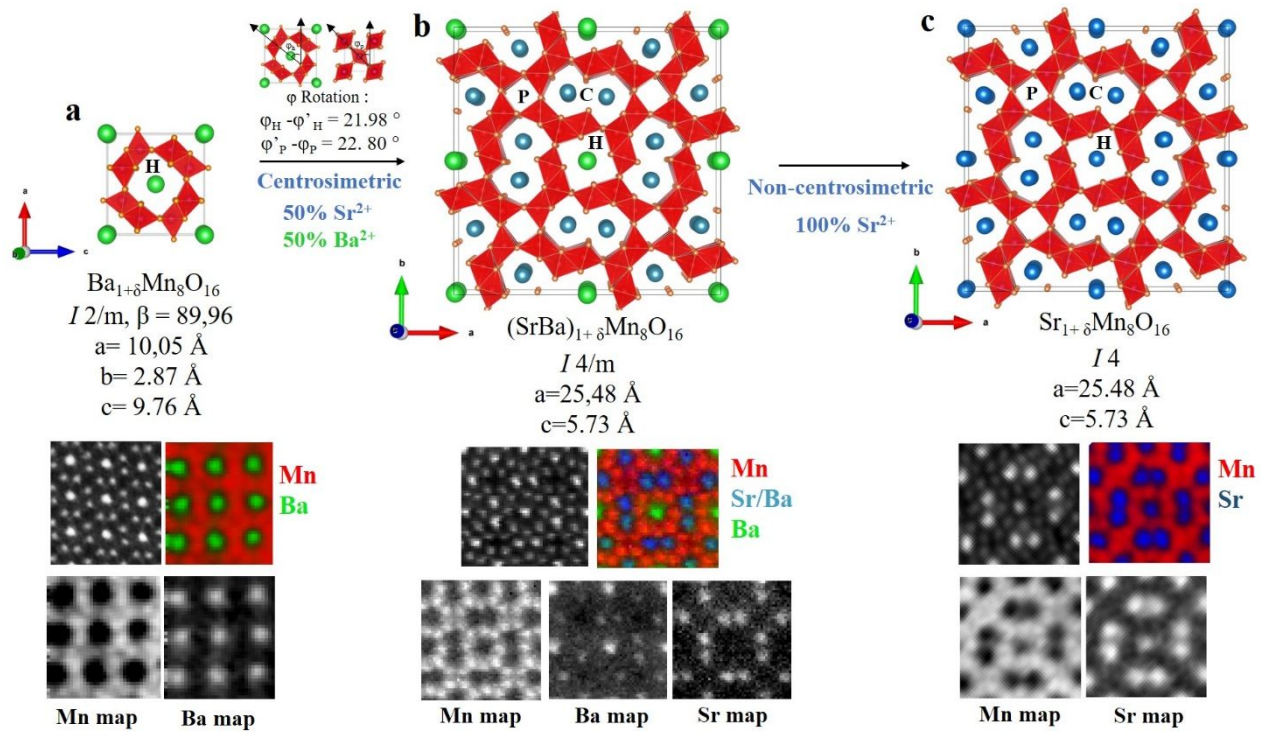


Figure 2. Crystallographic structures, composition and symmetry of: (a) BMO nanowire film (b) a BSMO nanowire film and (c) SMO nanowire film. Notice that in the novel SMO tetragonal structure, hollandites and pyrolusites blocks rotate 21.98° and 22.80° along φ angle respect to the well-known $\text{Ba}_{1+\delta}\text{Mn}_8\text{O}_{16}$ and pyrolusite (MnO_2) structures. The letter “H” in the structural models indicates that the atom belongs to the hollandite blocks or within the hollandite tunnels. The letter “P” indicates that the atom belongs to the pyrolusite blocks. The letter “C” indicates that the atoms are inside the new tunnels. The bottom panels of (a), (b) and (c) show the EELS elemental maps corresponding to the Mn L2,3, Ba M5,4 and Sr M4,5 edges along the [001] projection of the crystal structure of each individual nanowire unit cell.

Ferroelectric characterization of SMO nanowire films on silicon

We studied the ferroelectric properties at the micro and nanoscale of a 50 nm thick SMO nanowire film epitaxially stabilized on silicon with the DPFM technique [24]. For that purpose, we analyzed DPFM signals as a function of the scan direction on an antiparallel ferroelectric domain structure obtained by recording micro-range rectangular areas with a positive and negative sample bias of +20 and -20 VDC successively. Figure 3a describes the working principle of DPFM, where a metallic tip is used to scan the different ferroelectric domain structures induced in the SMO nanowire film; the blue color identifies a down domain polarization (noted as “Pdw”), while the

orange color recognizes an upwards polarization (noted as ‘‘Pup’’). The DPFM measurement was performed with the AFM working in contact mode. As the force is kept constant, the number of piezo-generated charges remains constant within the same ferro-electric domain, and it only changes when encounters and crosses a domain boundary. For instance, when the tip crosses the domain structures of figure 3a from left to right, a current is generated as the tip passes from the region of a negative charge accumulation (left side) to that of a positive charge accumulation (right side). When the tip scans back, the current changes its sign and flows in the opposite direction, as the tip goes from a positive charge accumulation (right side) to a negative charge accumulation region (left side). Such an imaging mechanism is unique because the only physical phenomenon that can produce such a contrast in an image is ferroelectricity. No other physical effect could induce a contrast reversal linearly dependent on the applied force and independent of the number of scans^[24,25]. Figure 3c shows two images of a SMO nanowire film acquired scanning towards the left (upper panel) and towards the right (lower panel). Both present clear current peaks right at the antiparallel ferroelectric domain boundaries. Notice that both images are approximately mirror-like reflections of each other and that the current sign changes when scanning along different directions. The right to left scanning is referred to as DPFM-Signal Output (DPFM-So, upper panel) and the left to right scanning is referred to as DPFM-Signal Input (DPFM-Si, lower panel). Figure 3d shows two characteristic profiles, extracted from the DPFM images measured for a SMO nanowire film, that clearly demonstrates that the current is inverted when the scanning direction is reversed, therefore confirming the ferroelectric behavior of the SMO nanowire studied.

Indeed, the SMO nanowire film can be electrically switched because the polarization axis of the *I4* tetragonal structure is parallel to the *c* axis, the longitudinal axis of nanowires, which generally lays flat on the silicon substrate. This allowed us to measure a similar ferroelectric

domain structure with PFM mode at room temperature. Figure 3e shows vertical piezoresponse force microscopy (VPFM) phase and VPFM amplitude signals and proves the switching of the SMO nanowire film using a bias of ± 20 VDV into an antiparallel natural domain structure configuration. Moreover, the profile extracted from the PFM images rules out any dielectric breakdown, see figure 3f. These results corroborate the previous DPFM measurements and thus the ferroelectric behavior of the SMO nanowire film.

In addition, we performed a comparative PFM study between the centrosymmetric BSMO, which displays a disorder of Ba and Sr atoms in the C tunnels and the non-centrosymmetric SMO in order to know if the particular cationic arrangement of the BSMO nanowires had any impact on the ferroelectric properties of these materials. Figure S8 and Figure S9 show the PFM study, which confirms the absence of ferroelectricity in the BSMO nanowire films. Therefore, we can conclude that the absence of ferroelectricity in the Ba doped SMO nanowire film is, most probably, due to the presence of Ba cations in the C tunnels, which increases the atomic disorder in this position and results in an average centrosymmetric structure. In this regard, a large number of studies have demonstrated the modification of several physical properties due to doping, such as the position of the foreign cation within hollandite tunnel structure^[29].

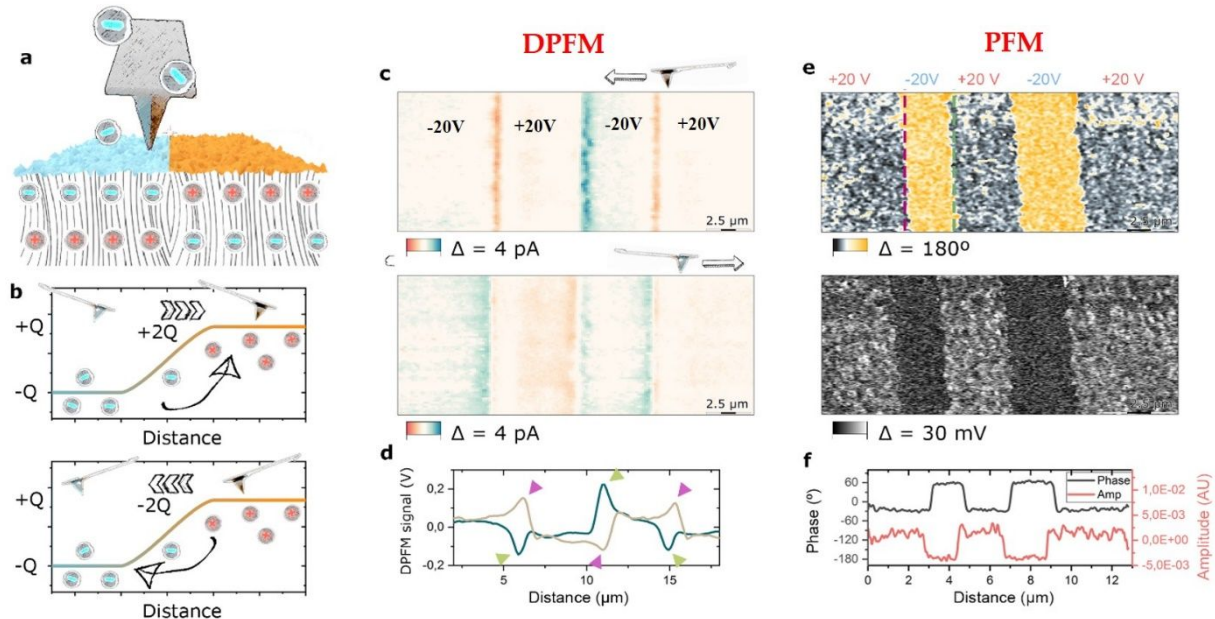


Figure 3. Ferroelectric characterization of SMO oxide nanowire films on silicon. (a) Scheme of the DPFM measurement of a SMO nanowire film, with an antiparallel up and downwards domain configuration. Upon application of a mechanical load, a negative charge is built up by the piezoelectric effect on the left side while a positive charge is built up at the right side (upper panel). The signal recorded, that is the current, is the derivative of the charge and it reverses its sign when the tip crosses different domains, depending upon the scan direction: the tip going from left to right and from right to left (lower panels, respectively), see (b). (c) DPFM images obtained for a SMO nanowire film with an antiparallel domain configuration. For a SMO nanowire film, the current sign is reversed as the scan direction changes, exactly as expected for a ferroelectric domain structure. (d) Random profiles extracted from a SMO nanowire film. (e) PFM analysis of the SMO ferroelectric antiparallel domain structure where VPFM phase and VPFM amplitude signals, upper and lower panel, respectively, confirm the switching of the nanowire film using a bias of ± 20 VDV. (f) Random profiles extracted from the VPFM phase and VPFM amplitude signals of the SMO nanowire film.

Piezoelectric characterization of SMO nanowire films on silicon

Based on the fact that all ferroelectric materials are also piezoelectric^[30], we studied the piezoelectric properties of SMO nanowire films using the DPFM technique. First, we maintained the AFM tip on the surface of the SMO nanowire thin film and simultaneously applied different force values, and then we measured the charges generated by the material. This allowed us to measure, with a high degree of precision, the piezoelectric constant d_{33} of the SMO nanowire film, which is the charge generated per unit force. To quantify the d_{33} value of SMO nanowire film, we directly integrate the peak current from the DPFM-Si image (see figure 4a). The values obtained

were 7.3 fC and -8.4 fC, which divided by an applied force of $211 \mu\text{N}$, yield a d_{33} value of 22 ± 6 pCN^{-1} (see figure 4a). The piezoelectric coefficient of SMO nanowire film was also measured using the conventional PFM technique, and it gave a d_{33} value of 14 ± 2 pm/V (see Figure. S10). The two piezoelectric coefficients are of the same order, confirming the piezoelectric functionality of SMO nanowire films by two different techniques. Notice that α -quartz nanometric interfacial layer cannot contribute to the piezoelectric properties of SMO nanowire film since it is polycrystalline and a non-polar piezoelectric material with an extremely low d_{33} value^[31]. These are important results and suggest the possibility to engineer, by chemical routes, piezoelectric films directly on silicon with thickness ranging from 50 to 300 nm that may produce a high charge collection and more efficient MEMS energy harvester devices^[32].

For a piezoelectric material, the recorded current should increase linearly with the applied load. Therefore, in the following experiments, we will show the response of the SMO nanowires film as a function of the applied force. Figure 4b shows the recorded DPFM-Si and DPFM-So images corresponding to a SMO nanowire sample under different applied loads, starting from a low loading force of $145 \mu\text{N}$ and then increased until reaching a maximum force of $269 \mu\text{N}$. Notice that, when the force is increased, the current recorded by the amplifier increases as well, confirming the piezoelectric nature of the generated charge in SMO nanowire film. Figure 4c shows a hybrid piezo generated charge and topographic mapping of a SMO nanowire film on silicon, which confirms that the piezoelectric charges are generated homogeneously through the nanowire film surface.

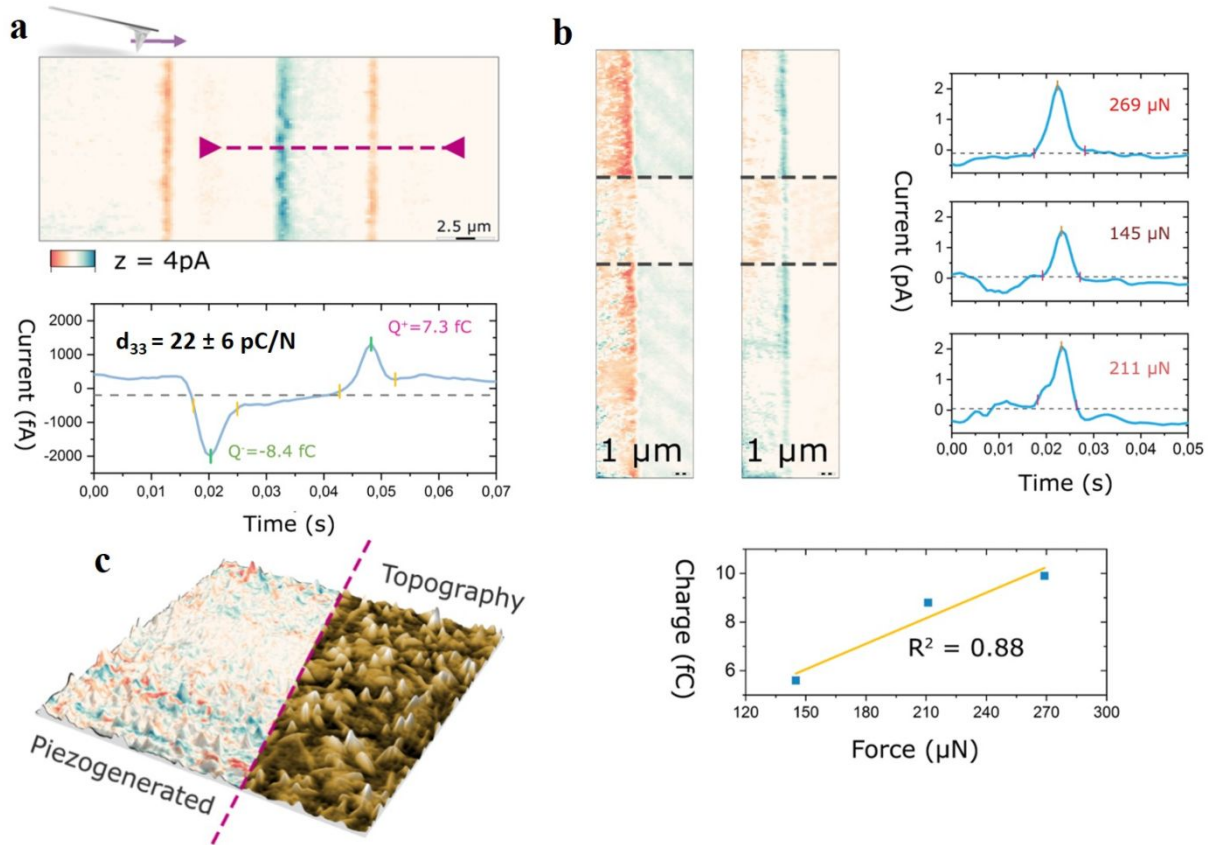


Figure 4. Piezoelectric characterization of SMO oxides nanowires film on silicon. (a) and (b) are recorded DPFM-Si and DPFM-So images, respectively, corresponding to a SMO nanowire film under different applied loads, starting from a low loading force of 145 μN till a maximum force of 269 μN . Lower panel in (a) shows the current vs. time profile along the dashed line in (a). Dashed lines in (b) separate regions in which different forces were applied. Right panel in (b) shows randomly selected profiles for the different applied forces. Lower panel in (b) shows the linear dependency of the force and the current recorded, confirming the piezoelectric nature of the generated charge in SMO nanowire film. (c) Hybrid piezo generated charge and topographic mapping of SMO nanowire film on silicon.

Piezoelectric nanogenerators based on ultra-long SMO hollandite-like nanowires.

Given the improved piezoelectric effect and excellent mechanical properties, one-dimensional (1D) piezoelectric nanostructures have been regarded as the next-generation piezoelectric material. In this light, 1D based nanogenerators can convert the mechanical energy into electricity by using piezoelectric 1D nanomaterials therefore exhibiting great potential in microscale power supply and sensor systems^[33]. Accordingly, we tested the strain-induced

piezoelectric polarization of flexible vertical ultra-long SMO nanowires by bending piezoelectric SMO nanowires and measuring the current obtained. We synthesized vertical 15 μm length SMO nanowires on highly doped silicon substrate using a 1D confined growth^[9] (Figure S11). Figure 5a shows a cross-sectional FEG-SEM image of an ultra-long epitaxial SMO nanowire film, and Figure 5b depicts the nanogenerator based on the bending of SMO nanowires induced by an AFM tip. The power generation mechanism involves the bending and the stretching of the SMO nanowires along the ferroelectric axis under a tensile state induced by the AFM tip, see the sketch Figure 5c. A piezoelectric potential difference induced by the strain appears in the SMO nanowires when the AFM tip exerts a force, which drives the carriers through an external load and accumulates them at the interface between the metallic AFM tip and the contacted nanowires. When the force exerted by the AFM tip is released, also does the tensile strain, then the piezoelectric potential difference disappears and the accumulated charges move back from the interface. Consequently, repeatedly bending and unbending the vertical SMO nanowires with a metallic AFM tip results in the generation of alternating current peaks. Figure 5c shows the functioning of the SMO nanowire nanogenerator, which converts the mechanical energy into electricity. It constitutes the first piezoelectric nanogenerator prototype based on vertical and ultralong SMO hollandites' nanowires grown directly on a silicon substrate. These results constitute a promising and complementary avenue towards novel 1D electric nanogenerators, most of them based on ZnO nanowires which exhibit a similar piezoelectric coefficient d_{33} of 14 pm/V^[34]. Moreover, ferroelectric SMO hollandite nanowires possess excellent deformability and can be removed from the silicon substrate and aligned through a gentle scratch^[35] on flexible Kapton substrate for being electrically contacted, as shown in Figure S12). This flexible manipulation and transfer of SMO nanowires makes this system a very promising material for applications in microelectronics.

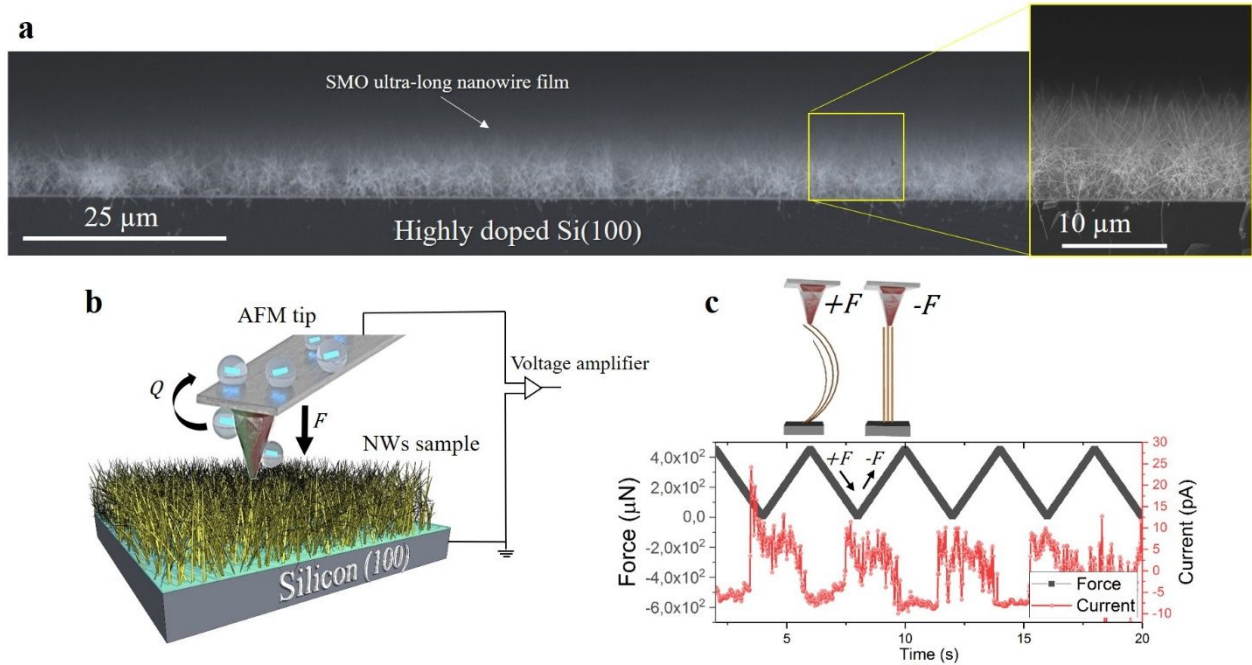


Figure 5. (a) cross-sectional FEG-SEM images of ultra-long epitaxial vertical SMO nanowire film on highly doped (100) silicon substrate. (b) sketch of the SMO nanogenerator based on nanowires bending induced by an AFM tip (c) The power generation mechanism involving the bending and unbending of the vertical SMO nanowire film with a metallic AFM tip, which results in the generation of the current peaks.

Conclusions

By using a cost-effective and scalable chemical method, we have integrated a room-temperature ferroelectric oxide in Si technology. Using a bottom-up chemical synthesis, we have been able to modify the chemical composition of hollandite nanowires directly grown on Si and to stabilize a new $\text{Sr}_{1+\delta}\text{Mn}_8\text{O}_{16}$ hollandite-like structure. The combination of scanning transmission electron microscopy and crystallographic computing revealed a novel structural model of $\text{Sr}_{1+\delta}\text{Mn}_8\text{O}_{16}$ nanowires comprising hollandite and pyrolusite units sharing the edges of their MnO_6 octahedra, resulting in three types of tunnels arranged along the c axis. The ordering of Sr atoms within the tunnels breaks the symmetry and gives rise to a ferroelectricity and piezoelectricity (d_{33}

value of 22 ± 6 pC/N), which have been locally examined using conventional and Direct-PFM techniques.

From a technological perspective, this novel hollandite oxide directly integrated on silicon opens the way for developing active devices engineered from lead-free ferroelectric oxide materials. Indeed, we have used ultra-long and vertical $\text{Sr}_{1+\delta}\text{Mn}_8\text{O}_{16}$ nanowires as a nanogenerator prototype, which rendered an excellent deformability and high interface recombination. Besides, these ultra-long ferroelectric nanowires are easy to manipulate and transfer to flexible substrates making this system a very promising material for applications in microelectronics.

Experimental Section

Thin film crystal nanowires growth.

$\text{Sr}_{1+\delta}\text{Mn}_8\text{O}_{16}$ nanowire thin films were prepared from 1M $\text{Sr}(\text{Ac})_2$ in acetic solution and 1M $\text{Mn}(\text{Ac})_2$ in water solution. This range of proportions made possible to stabilize, at any of the conditions, the corresponding nanowire thin film. The final synthesis step entails mixing the previous Sr and Mn solution into 2 volumes of ethanol with the objective to enhance the layer adhesion and further optimal evaporation of the solvent (e.g. 5 mL of 1M $\text{Sr}(\text{Ac})_2$, 5 mL 1M of $\text{Mn}(\text{Ac})_2$ in 10 mL of ethanol). 30 μL of final solution with Sr/Mn (1:1) was spin coated (3,000 rpm, 20 s) on 50 x 50 mm² (100) Si single-crystalline substrates. A thermal treatment of 750 °C for 2 h (ramp temperature 3 °C min⁻¹) in air was applied directly after spin coating in a tubular oven in order to obtain epitaxial oxide nanowire films on silicon substrates.

$(\text{BaSr})_{1+\delta}\text{Mn}_8\text{O}_{16}$ nanowire thin films were prepared from 1M $\text{Sr}(\text{Ac})_2$ and 1M $\text{Ba}(\text{OH})_2$ in acetic solutions, and 1M $\text{Mn}(\text{Ac})_2$ in water solution. This range of proportions made possible to stabilize, at any of the conditions, the corresponding nanowire thin film. The final synthesis step entails mixing the previous Sr, Ba and Mn solution into 2 volumes of ethanol with the objective to enhance

the layer adhesion and further optimal evaporation of the solvent (e.g. 5 mL of 1M Ba(OH)₂, 5 mL 1M of Mn(Ac)₂ in 10 mL of ethanol). 30 μL of final solution with Sr/Mn (1:1) was spin coated (4,000 rpm, 20 s) on 50 x 50 mm² (100) Si single-crystalline substrates. A thermal treatment of 800 °C for 2 h (ramp temperature 3 °C min⁻¹) in air was applied directly after spin coating in a tubular oven in order to obtain epitaxial oxide nanowire films on silicon substrates.

Ba_{1+δ}Mn₈O₁₆ nanowire thin films were prepared from 1M Ba(OH)₂ in acetic solution and 1M Mn(Ac)₂ in water solution. This range of proportions made possible to stabilize, at any of the conditions, the corresponding nanowire thin film. The final synthesis step entails mixing the previous Ba and Mn solution into 2 volumes of ethanol with the objective to enhance the layer adhesion and further optimal evaporation of the solvent (e.g. 5 mL of 1M Ba(OH)₂, 5 mL 1M of Mn(Ac)₂ in 10 mL of ethanol). 30 μL of final solution with Sr/Mn (1:1) was spin coated (3,000 rpm, 20 s) on 50 x 50 mm² (100) Si single-crystalline substrates. A thermal treatment of 800 °C for 2 h (ramp temperature 3 °C min⁻¹) in air was applied directly after spin coating in a tubular oven in order to obtain epitaxial oxide nanowire films on silicon substrates.

Ultra-long SMO nanowires synthesis.

Sr_{1+δ}Mn₈O₁₆, ultra-long nanowire films on silicon were synthesized using commercial nanoporous track etched polyimide (PI) templates (7 μm thick and 200 nm of pore diameter) provided by it4ip s.a. (Belgium). This PI porous sheet is directly supported on the Si substrate and then impregnated by capillarity forces with a mixed precursor solution containing 5 mL 1M Sr(Ac)₂ in acetic acid, 5 mL 1M of Mn(Ac)₂ in water and 10 mL of ethanol. Finally, a thermal treatment at 800 °C for 5 h (ramp temperature 3 °C min⁻¹) in air was applied directly in a tubular oven in order to obtain vertical epitaxial OMS nanowires on a silicon substrate.

AFM characterization

The measurements were performed using a Keysight 5500LS while a special ultra-low leakage amplifier is used in trans-impedance configuration (TIA) with part number ADA4530-1. The TIA amplifier is populated with a 10 GΩ feedback resistor, which give us a current noise level of

1:59 fA/Hz^{0.5} while the leakage current in these conditions is maintained at less than 10 fA – data obtained from the amplifier datasheet of Analog Devices Inc. At the output of the current amplifier, a cascade voltage amplifier increases the overall gain of the system. The RC time constant of the amplifier is estimated at 6 ms, which equals a strain feedback capacitor of 0.1 pC. The two cascade amplifiers are calibrated with a known test resistor and a known bias applied, to see the calibration curves. In order to calculate the force used, we employed a standard method based on force vs. distance curves, performed in spectroscopy mode to acquire the tip deflection sensitivity. This value is used to convert the difference between the free deflection value and the set point value into force units, by using the cantilever spring constant. All measurements were performed in low humidity conditions, less than 8%, to avoid possible electrochemical effects.

Structural and chemical characterization

Hollandite like nanowires structure was investigated using a field emission gun scanning electron microscope (FEG-SEM), Hitachi's SU77. Scanning Transmission Electron Microscopy (STEM) studies were conducted on cross sectional TEM lamellas prepared by Ga⁺ Focused Ion Beam (FIB) in a Thermo Fisher Helios Dual Beam. STEM analysis was carried out in a FEI Titan operated at 300 kV and equipped with a high-brightness field emission gun (X-FEG), a CETCOR aberration corrector for probe from CEOS GmbH and a Gatan Imaging Filter (GIF) Tridiem 866 ERS, and with a Nion UltraSTEM, operated at 100 kV and equipped with a Nion aberration corrector and a Gatan Enfina EEL spectrometer. In these microscopes, the aberration-corrected probe yields a routine spatial resolution below 1 Å, and the HAADF imaging allows recording incoherent Z-contrast images, in which the contrast of an atomic column is approximately proportional to the square of the average atomic number (Z). Reciprocal space reconstruction and determination of the different unit cells were investigated by using a JEOL 1210 transmission electron microscope operating at 120 KV, equipped with a side-entry 60/30° double tilt Gatan 646 analytical specimen holder and a link QX2000 XEDS element analysis system. X-ray diffraction measurements were carried out using a 6-circle diffractometer at Soleil Synchrotron equipped with a 2D detector Rayonix SX165. This detector is composed of a CCD camera, 165 mm diameter, 40 μm pixel size min. 4096x4096 pixels Pixel size: 40x40 μm² (min).

Electrodes deposition and lithographic process

Contact electrodes on aligned ultra-long SMO nanowires were performed by using a AZ2020 negative resist that was spin coated on Teflon substrate and patterned using EVG 620 UV lithography for the 50 nm of Cr and 120 nm of Au metal deposition. Lift off process was completed after 2 hours by using organic solvent photoresist remover PG at 80°C.

Acknowledgements

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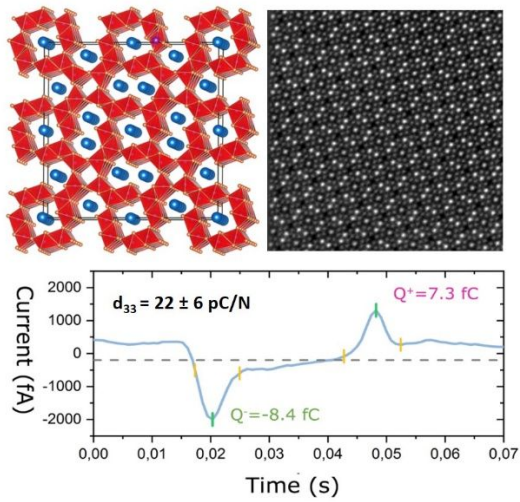
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A simple chemical method is developed to integrate a novel room-temperature ferroelectric $\text{Sr}_{1+\delta}\text{Mn}_8\text{O}_{16}$ hollandite-like oxide nanowire thin film in silicon technology. This work combines scanning transmission electron microscopy with crystallographic computing to reveal a natural symmetry breaking mechanism due to the ordering of Sr atoms giving rise to a ferroelectricity and piezoelectricity.



SUPPORTING INFORMATION

Crystal Engineering and Ferroelectricity at the Nanoscale in Epitaxial 1D Manganese Oxide on Silicon

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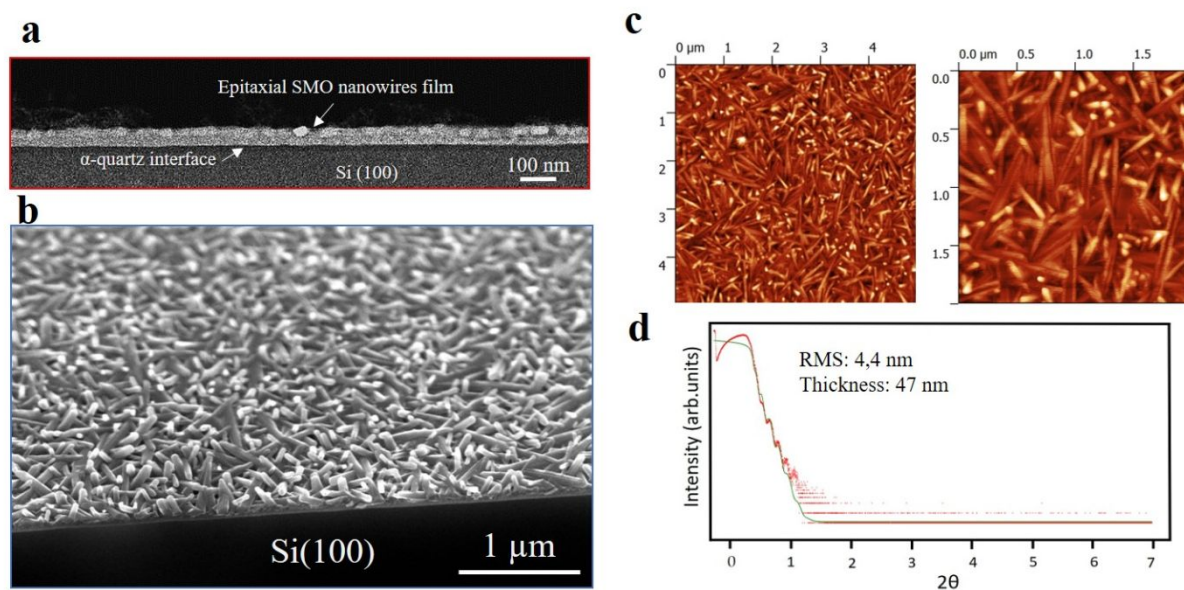


Figure S1. (a) Cross-sectional low-resolution HAADF-STEM image of the nanowire film (b) Cross-sectional tilted SEM-FEG image of an epitaxial $\text{Sr}_{1+\delta}\text{Mn}_8\text{O}_{16}$ nanowire film on a silicon substrate (c) AFM topographic characterization of a SMO nanowire thin film. (d) X-ray reflectometry analysis of a SMO nanowire film showing a RMS of 4.4 nm and a thickness of 47 nm.

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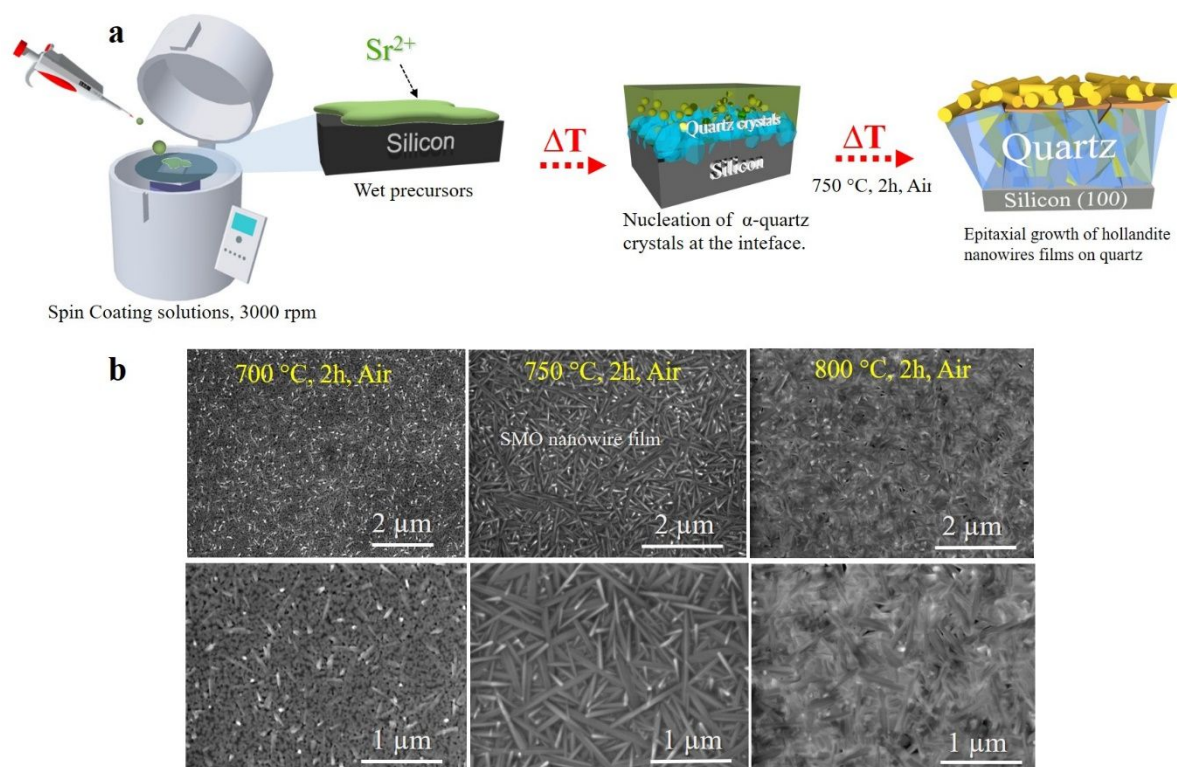


Figure S2. Growth mechanism and synthesis methods of SMO nanowire thin film on silicon Si (100) substrates. (a) Schematics representation of the different steps growth of epitaxial SMO nanowires i.e. (i) a first stage where a film chemical precursor solution containing Sr^{2+} melting agents and Mn^{4+} salt is deposited on a Si substrate by using spin-coating technique; (ii) next step involves the 2D-confined nucleation in thin film form of oxide nanowires seeds and first devitrification and nucleation of disoriented quartz crystals at the silicon interface; (iii) finally α -quartz film formation at higher temperatures (750 °C), allowing the epitaxial stabilization of SMO hollandite-like nanowire thin film. (b) Series of FEG-SEM images showing the crystallization and growth of SMO nanowire film on silicon at different temperatures.

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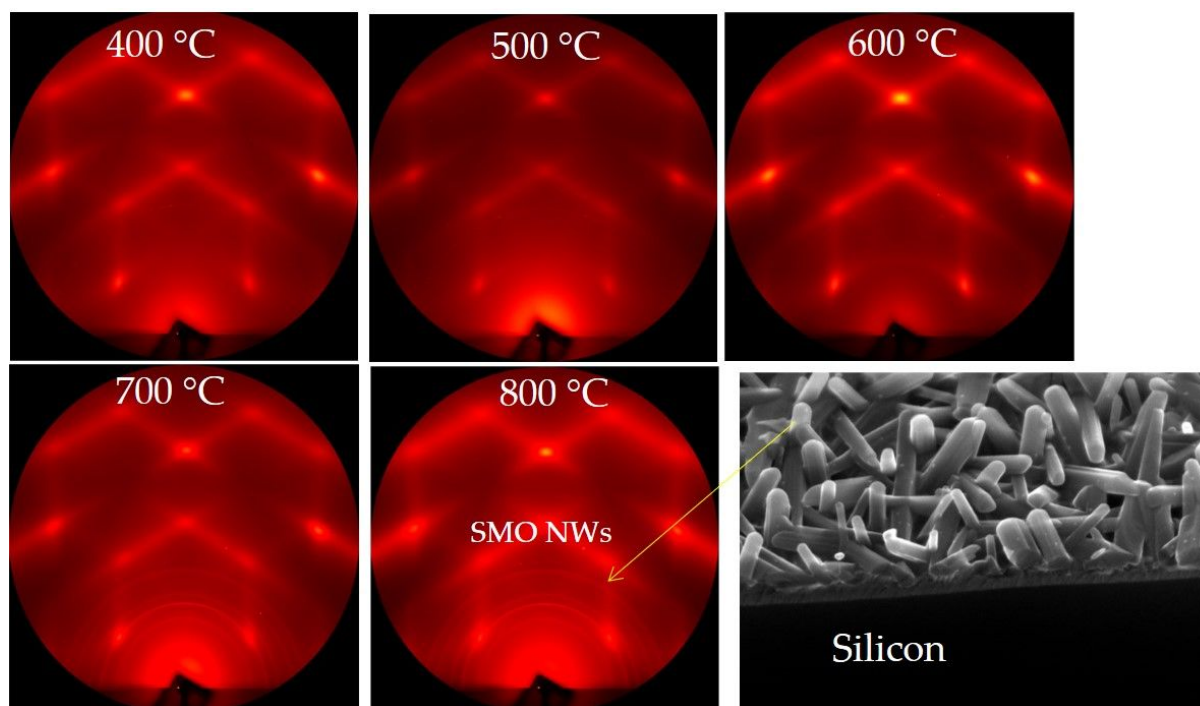


Figure S3. Observation of the SMO nanowires crystallization thin films on silicon by temperature-resolved synchrotron X-ray diffraction. The diffraction pattern is dominated by the thermal diffuse scattering of silicon, the Debye-Scherrer rings observed clearly at 700°C and 800°C correspond to the diffraction pattern of SMO nanowires.

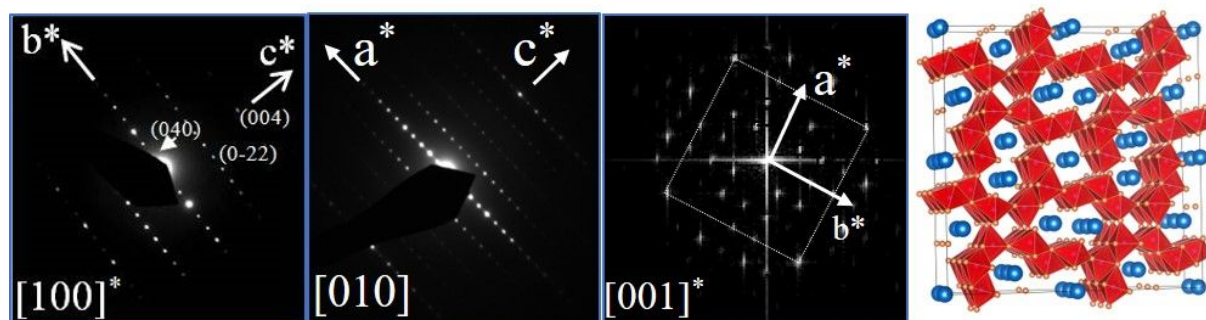


Figure. S4. The three basis planes of the SMO crystallographic unit cell. Notice that the diffraction patterns for the Sr-case do not present satellites or prominent diffuse scattering. The doubling of the c-axis with respect to the $\text{Ba}_{6-x}\text{Mn}_{24}\text{O}_{48}$ is well established in the electron diffraction patterns of our compound. In the structure show which color corresponds to each cation.

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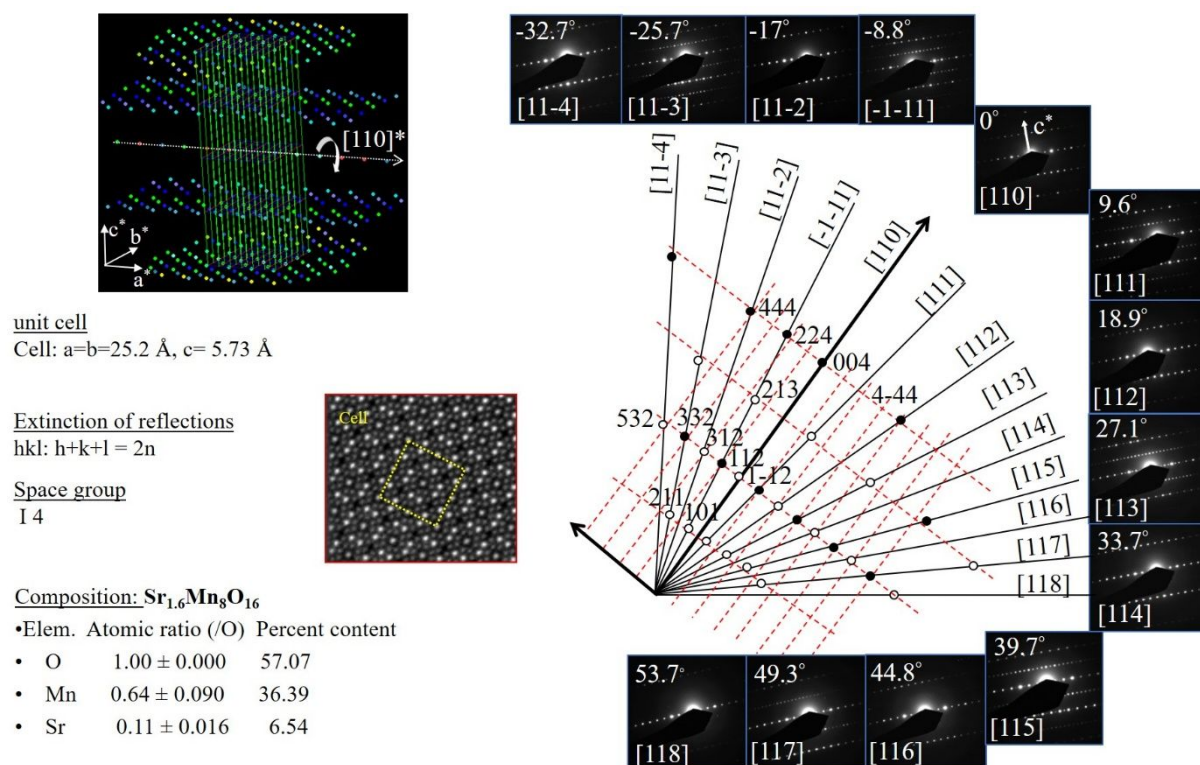


Figure S5. Reciprocal space reconstruction along the [110] crystallographic direction of a single SMO nanowire by using electron diffraction. Electron diffraction spots in the reciprocal space show that (hkl) reflection conditions and systematic absences can be indexed in a pseudo-tetragonal body centered cell with lattice parameters $a = 25.2 \text{ \AA}$, $c = 5.7 \text{ \AA}$, $\alpha = \beta = \gamma = 90^\circ$ compatible with a non-centrosymmetric space group $I4$. EDX analysis of the SMO structure showed a composition $\text{Sr}_{1.4}\text{Mn}_8\text{O}_{16}$.

Table S1

Atomic positions of the model explaining the atomic-resolution STEM images that correspond to the non-centrosymmetric polar space group $I4$ with unit cell parameters $a_1=25.488 \text{ \AA}$, $c_1=5.753 \text{ \AA}$. The letter “h” in the label of atoms indicates that the atom belongs to the hollandite blocks or within the hollandite tunnels. The letter “p” indicates that the atom belongs to the pyrolusite blocks. The letter “m” indicates that the atom is shared by the pyrolusite and hollandite blocks and the letter “c” indicates that the atoms are inside the new tunnels. Coordinates of different atom in the input structure are frequently equal in value because we have constructed the model from the centrosymmetric structure described in [1]. Only the Sr-atoms break the centre of symmetry of the global structure in the input structure. The optimized crystal structure against bond-valence in the space group $I4$ breaks the inversion centre with all atoms and it does not change too much the positions. The standard deviations in the positions of the relaxed structure correspond to the fluctuations intrinsic to the optimization algorithm. The calculated bond-valence sums and global instability indices are provided after the table of atom positions.

Note: Using the composition, $\text{Sr}_3\text{Mn}_{12}\text{O}_{24}$ (or $\text{Sr}_2\text{Mn}_8\text{O}_{16}$) we have optimized the position of the atoms using the program *GLOpSAnn*, distributed within the *FullProf Suite* [2], which allows applying different kind of cost functions to structural solution, or optimisation using Simulated Annealing followed by local optimization. As we do not have adequate diffraction data, we have used bond-valence and anti-bump as cost functions to be optimized against atom positions. In order to prevent too short atom contacts, the anti-bump penalty function $ab=(d_{\min}/d)^{12}$ has been used for each pair of chemical element

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(see documentation of *GLOPAnn*). We have started with the ideal generated atom positions by the program *Similar* (coordinate triplets on the left of the table) and we have allowed the atoms to move within a box of 0.2 Å side in the three spatial directions around the input positions. With that method, we get a final crystal structure, close to the input structure, that minimizes the difference between the ionization state number and the bond-valence sums around each ion. We have assumed bond-valence parameters for Mn⁴⁺, Mn³⁺, Sr²⁺ and O²⁻, placing the Mn⁴⁺ in the pyrolusite blocks. In the real compound, the composition has to be adapted by diminishing the occupation factors of the Sr within the hollandite tunnels.

Atom	Type	x/a	y/b	z/c	Wyckoff site	x/a	y/b	z/c
Srh1	Sr	0.50000	0.50000	0.00000	(2a)	0.50000	0.50000	-0.0058 (3)
Srh2	Sr	0.50000	0.00000	0.23300	(4b)	0.50000	0.00000	0.2265 (3)
Src3	Sr	0.57316	0.74297	0.50000	(8c)	0.56921 (5)	0.74666 (5)	0.4935 (2)
Src4	Sr	0.42623	0.75970	0.49708	(8c)	0.56999 (7)	0.23882 (4)	-0.0081 (2)
Mnp1	Mn	0.18750	0.18062	0.25000	(8c)	0.18428 (5)	0.17720 (7)	0.2660 (2)
Mnp2	Mn	0.18750	0.18062	0.75000	(8c)	0.19179 (4)	0.17795 (6)	0.7619 (3)
Mnp3	Mn	0.68749	0.18061	0.00000	(8c)	0.68886 (6)	0.17874 (5)	0.0158 (3)
Mnp4	Mn	0.68749	0.18061	0.50000	(8c)	0.68831 (7)	0.17683 (5)	0.5174 (2)
Mnh1	Mn	0.11010	0.10522	0.00000	(8c)	0.11090 (4)	0.10152 (7)	-0.0034 (3)
Mnh2	Mn	0.11010	0.10522	0.50000	(8c)	0.11218 (7)	0.10209 (5)	0.5032 (2)
Mnh3	Mn	0.61011	0.10522	0.25000	(8c)	0.61121 (6)	0.10144 (6)	0.2466 (2)
Mnh4	Mn	0.61011	0.10522	0.75000	(8c)	0.60601 (7)	0.10380 (7)	0.7345 (3)
Mnh5	Mn	0.51300	0.86000	0.00000	(8c)	0.51281 (4)	0.85583 (4)	0.0145 (3)
Mnh6	Mn	0.51300	0.86000	0.50000	(8c)	0.50945 (4)	0.85615 (6)	0.5127 (2)
Mnh7	Mn	0.51300	0.36000	0.25000	(8c)	0.51172 (3)	0.35645 (7)	0.2417 (3)
Mnh8	Mn	0.51300	0.36000	0.75000	(8c)	0.51053 (6)	0.35588 (5)	0.7550 (3)
Op1	O	0.76310	0.82521	0.00000	(8c)	0.76722 (5)	0.82221 (7)	-0.0170 (2)
Op2	O	0.76310	0.82521	0.50000	(8c)	0.76687 (5)	0.82128 (5)	0.5095 (3)
Op3	O	0.26310	0.82521	0.25000	(8c)	0.26646 (6)	0.82275 (7)	0.2344 (3)
Op4	O	0.26310	0.82521	0.75000	(8c)	0.26675 (5)	0.82358 (6)	0.7353 (2)
Om1	O	0.63633	0.67670	0.00000	(8c)	0.64046 (6)	0.68100 (3)	-0.0163 (3)
Om2	O	0.63633	0.67670	0.50000	(8c)	0.63998 (8)	0.68092 (4)	0.5056 (3)
Om3	O	0.63633	0.17670	0.25000	(8c)	0.64050 (6)	0.18057 (6)	0.2325 (3)
Om4	O	0.63633	0.17670	0.75000	(8c)	0.63996 (7)	0.18068 (4)	0.7327 (2)
Om5	O	0.59750	0.84062	0.00000	(8c)	0.60110 (8)	0.83713 (4)	0.0156 (3)
Om6	O	0.59750	0.84062	0.50000	(8c)	0.60149 (6)	0.83650 (4)	0.4957 (3)
Om7	O	0.59751	0.34061	0.25000	(8c)	0.60121 (6)	0.33651 (6)	0.2561 (3)
Om8	O	0.59751	0.34061	0.75000	(8c)	0.60094 (6)	0.33677 (5)	0.7505 (2)
Oh1	O	0.62108	0.94023	0.00000	(8c)	0.62140 (8)	0.94180 (7)	-0.0116 (3)
Oh2	O	0.62108	0.94023	0.50000	(8c)	0.62099 (7)	0.93909 (7)	0.5004 (3)
Oh3	O	0.12108	0.94023	0.25000	(8c)	0.12133 (8)	0.94091 (6)	0.2489 (3)
Oh4	O	0.12108	0.94023	0.75000	(8c)	0.11760 (7)	0.93949 (6)	0.7395 (3)
Oh5	O	0.09046	0.02477	0.00000	(8c)	0.08826 (7)	0.02554 (6)	0.0029 (3)
Oh6	O	0.09046	0.02477	0.50000	(8c)	0.08674 (7)	0.02300 (4)	0.5009 (3)
Oh7	O	0.59045	0.02477	0.25000	(8c)	0.58693 (8)	0.02794 (6)	0.2556 (4)
Oh8	O	0.59045	0.02477	0.75000	(8c)	0.58910 (3)	0.02522 (6)	0.7635 (3)
Oh9	O	0.50488	0.68855	0.00000	(8c)	0.50205 (6)	0.69283 (6)	0.0105 (3)
Oh10	O	0.50488	0.68855	0.50000	(8c)	0.50285 (5)	0.69245 (5)	0.4987 (3)
Oh11	O	0.50488	0.18855	0.25000	(8c)	0.50679 (7)	0.19255 (6)	0.2349 (3)
Oh12	O	0.50488	0.18855	0.75000	(8c)	0.50717 (6)	0.19201 (7)	0.7596 (3)

SUPPORTING INFORMATION

Calculated average distances distortion and bond-valence sums, for all the atoms in the asymmetric unit, of the initial idealized model generated by the program *Similar* from the *I4/m* model of $\text{Ba}_{6-x}\text{Mn}_{24}\text{O}_{48}$ [1], after transforming the unit cell $\mathbf{a}_B=18.173(2)$ Å, $\mathbf{c}_B=2.836(1)$ to $\mathbf{a}_T=\mathbf{a}_B+\mathbf{b}_B$, $\mathbf{b}_T=-\mathbf{a}_B+\mathbf{b}_B$ and $\mathbf{c}_T=2\mathbf{c}_B$. We have adjusted the cell parameters to $a_T=25.488$ Å, $c_T=5.753$ Å in the space group *I4*. The global instability index is 12.14%.

Atom	Coord	D_aver	Sigm	Distort (x10-4)	Valence	BVSum (Sigma)
Srh1	4.00	2.3906	(0)	0.001	2.000	1.915 (0)
Srh2	4.00	2.3923	(0)	0.000	2.000	1.906 (0)
Src3	7.00	2.7375	(0)	143.151	2.000	1.964 (0)
Src4	9.00	2.7862	(0)	35.039	2.000	1.612 (0)
Mnp1	6.00	2.0144	(0)	37.237	4.000	3.111 (0)
Mnp2	6.00	2.0144	(0)	37.237	4.000	3.111 (0)
Mnp3	6.00	2.0144	(0)	37.254	4.000	3.110 (0)
Mnp4	6.00	2.0144	(0)	37.254	4.000	3.110 (0)
Mnh1	6.00	1.9716	(0)	11.022	3.000	3.436 (0)
Mnh2	6.00	1.9716	(0)	11.022	3.000	3.436 (0)
Mnh3	6.00	1.9715	(0)	11.067	3.000	3.437 (0)
Mnh4	6.00	1.9715	(0)	11.067	3.000	3.437 (0)
Mnh5	6.00	1.9840	(0)	26.248	3.000	3.382 (0)
Mnh6	6.00	1.9840	(0)	26.248	3.000	3.382 (0)
Mnh7	6.00	1.9839	(0)	26.319	3.000	3.383 (0)
Mnh8	6.00	1.9839	(0)	26.319	3.000	3.383 (0)
Op1	3.00	1.9873	(0)	24.821	-2.000	1.646 (0)
Op2	4.00	2.1507	(0)	188.972	-2.000	1.890 (0)
Op3	4.00	2.2423	(0)	402.312	-2.000	1.737 (0)
Op4	4.00	2.2423	(0)	402.312	-2.000	1.737 (0)
Om1	3.00	1.9430	(0)	0.007	-2.000	1.807 (0)
Om2	4.00	2.0406	(0)	68.702	-2.000	2.365 (0)
Om3	4.00	2.1424	(0)	260.373	-2.000	1.993 (0)
Om4	4.00	2.1424	(0)	260.373	-2.000	1.993 (0)
Om5	4.00	2.0712	(0)	53.889	-2.000	1.867 (0)
Om6	5.00	2.1700	(0)	122.159	-2.000	2.166 (0)
Om7	5.00	2.2453	(0)	276.425	-2.000	1.974 (0)
Om8	5.00	2.2453	(0)	276.425	-2.000	1.974 (0)
Oh1	3.00	1.9517	(0)	1.631	-2.000	1.791 (0)
Oh2	4.00	2.2452	(0)	513.407	-2.000	1.857 (0)
Oh3	3.00	1.9516	(0)	1.622	-2.000	1.791 (0)
Oh4	3.00	1.9516	(0)	1.622	-2.000	1.791 (0)
Oh5	3.00	1.9951	(0)	16.809	-2.000	1.626 (0)
Oh6	4.00	2.0940	(0)	78.326	-2.000	2.105 (0)
Oh7	4.00	2.0945	(0)	78.824	-2.000	2.102 (0)
Oh8	4.00	2.0945	(0)	78.824	-2.000	2.102 (0)
Oh9	3.00	2.1830	(0)	225.290	-2.000	1.432 (0)
Oh10	3.00	2.0427	(0)	40.041	-2.000	1.940 (0)
Oh11	4.00	2.3911	(0)	366.968	-2.000	1.519 (0)
Oh12	4.00	2.3911	(0)	366.968	-2.000	1.519 (0)

Normalized GII(b)=SUM { |BVS-abs (q) | *mult/abs (q) }/N_Atoms_UCell = 12.14 %

SUPPORTING INFORMATION

Calculated average distances, distortion and bond-valence sums, for all the atoms in the asymmetric unit, of the optimized model obtained by the program *GLOpSAnn*, in the space group *I4*. The global instability index is 4.53%.

Atom	Coord	D_aver	Sigm	Distort (x10 ⁻⁴)	Valence	BVSum (Sigma)
Srh1	4.00	2.2876	(7)	-0.001	2.000	2.529 (5)
Srh2	4.00	2.3516	(9)	0.602	2.000	2.130 (5)
Src3	7.00	2.7397	(7)	162.876	2.000	2.018 (5)
Src4	9.00	2.7451	(7)	69.191	2.000	2.000 (5)
Mnp1	6.00	1.9643	(9)	91.033	4.000	3.825 (10)
Mnp2	6.00	1.9706	(9)	116.282	4.000	3.914 (10)
Mnp3	6.00	1.9685	(8)	96.332	4.000	3.832 (11)
Mnp4	6.00	1.9753	(8)	111.408	4.000	3.819 (10)
Mnh1	6.00	2.0182	(9)	12.007	3.000	3.037 (7)
Mnh2	6.00	2.0251	(8)	16.634	3.000	3.003 (7)
Mnh3	6.00	2.0170	(9)	10.275	3.000	3.039 (8)
Mnh4	6.00	2.0171	(10)	18.543	3.000	3.077 (9)
Mnh5	6.00	2.0391	(9)	49.791	3.000	3.027 (8)
Mnh6	6.00	2.0538	(9)	75.618	3.000	3.004 (8)
Mnh7	6.00	2.0402	(9)	54.138	3.000	3.022 (8)
Mnh8	6.00	2.0421	(9)	58.461	3.000	3.021 (8)
Op1	3.00	2.0061	(11)	194.350	-2.000	2.002 (7)
Op2	4.00	2.1985	(10)	369.860	-2.000	2.001 (7)
Op3	4.00	2.2763	(11)	546.788	-2.000	1.984 (8)
Op4	4.00	2.2810	(9)	574.045	-2.000	2.001 (7)
Om1	3.00	1.9630	(11)	105.445	-2.000	2.000 (7)
Om2	4.00	2.1062	(11)	120.393	-2.000	2.073 (7)
Om3	4.00	2.1654	(11)	256.989	-2.000	2.000 (7)
Om4	4.00	2.1751	(11)	282.973	-2.000	1.988 (7)
Om5	4.00	2.0725	(11)	45.253	-2.000	1.823 (6)
Om6	5.00	2.1948	(9)	72.881	-2.000	1.996 (5)
Om7	5.00	2.2660	(9)	320.709	-2.000	1.929 (6)
Om8	5.00	2.2534	(9)	290.426	-2.000	1.941 (5)
Oh1	3.00	1.9161	(14)	15.191	-2.000	2.008 (8)
Oh2	4.00	2.2304	(12)	410.095	-2.000	1.792 (6)
Oh3	3.00	1.9820	(13)	16.977	-2.000	1.689 (6)
Oh4	3.00	1.9638	(13)	2.055	-2.000	1.735 (6)
Oh5	3.00	2.0597	(13)	1.948	-2.000	1.338 (5)
Oh6	4.00	2.1223	(10)	22.684	-2.000	1.947 (5)
Oh7	4.00	2.1240	(12)	38.522	-2.000	1.932 (6)
Oh8	4.00	2.1241	(9)	44.782	-2.000	1.906 (5)
Oh9	3.00	2.1156	(13)	197.880	-2.000	1.680 (6)
Oh10	3.00	2.0349	(12)	27.057	-2.000	2.000 (6)
Oh11	4.00	2.3083	(11)	299.376	-2.000	1.793 (6)
Oh12	4.00	2.3075	(11)	306.586	-2.000	1.777 (6)

Normalized GII(b) = $\text{SUM} \{ |BVS - \text{abs}(q)| * \text{mult} / \text{abs}(q) \} / N_Atoms_UCell = 4.53 \%$

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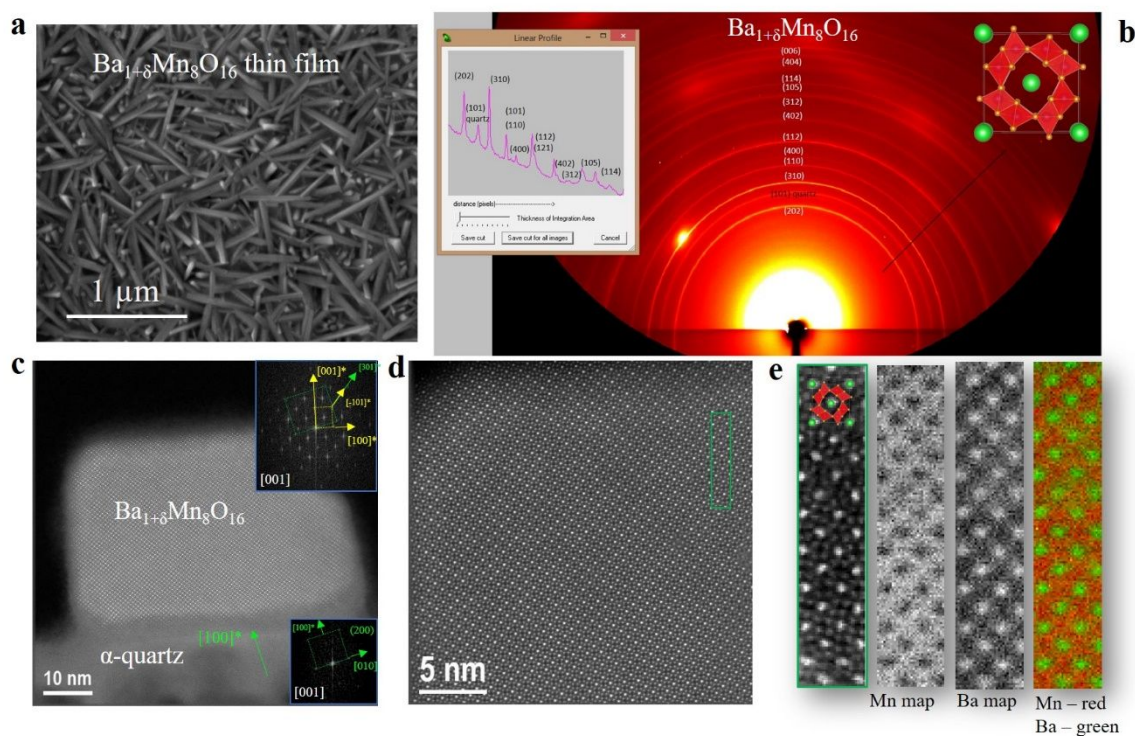


Figure S6. Chemical growth of epitaxial Barium oxide hollandite nanowire film on silicon. (a) FEG-SEM image showing the microstructural aspect and homogeneity of the $\text{Ba}_{1+\delta}\text{Mn}_8\text{O}_{16}$ thin films. (b) Grazing incidence 2D synchrotron X-ray diffractometer of a $\text{Ba}_{1+\delta}\text{Mn}_8\text{O}_{16}$ nanowire film. Notice that with this technique we are able to observe all the reflections corresponding to the monoclinic crystallographic structure without any secondary phases. (c) HAADF-STEM image of a $\text{Ba}_{1+\delta}\text{Mn}_8\text{O}_{16}$ nanowire along the longitudinal nanowire axis i.e. $[010]$ crystallographic direction epitaxially grown on top of the α -quartz layer. The insets show the FFT images that indicates the epitaxial relationship between both phases i.e. (110) SMO $[-101] \parallel (110)$ α -quartz $[301]$ (d) Detailed HAADF-STEM image of a $\text{Ba}_{1+\delta}\text{Mn}_8\text{O}_{16}$ nanowire along the longitudinal nanowire axis i.e. $[010]$ crystallographic direction. (e) EELS atomic-resolution chemical mapping of Mn and Ba elements of a $\text{BaMn}_8\text{O}_{16}$ nanowire along the $[010]$ crystallographic direction.

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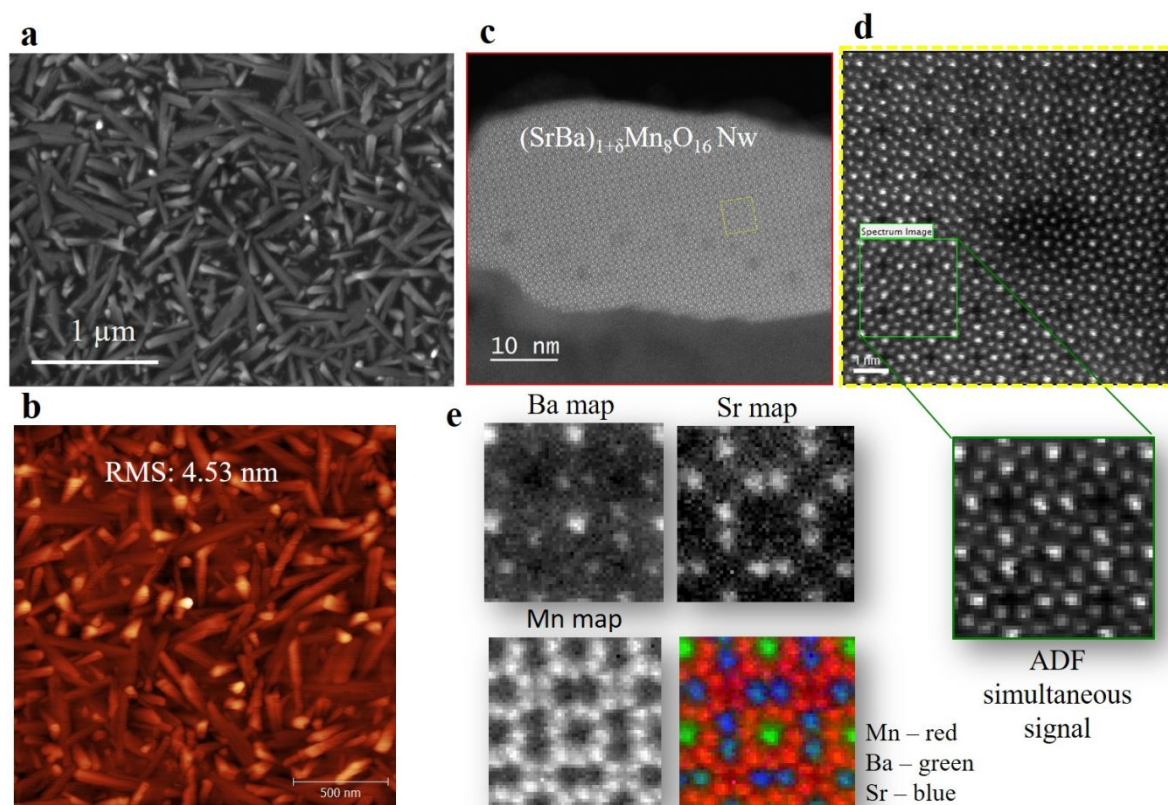


Figure S7. Chemical growth of Barium-doped SMO manganite nanowire film on silicon. Serie of FEG-SEM (a) and AFM (b) images showing the microstructural aspect, homogeneity and roughness of the thin film. (c) HAADF-STEM image of a BSMO nanowire along the longitudinal nanowire axis i.e. [001] crystallographic direction epitaxially grown on top of the α -quartz layer. (d). HAADF-STEM images of a BSMO nanowire along the longitudinal nanowire axis i.e. [001] crystallographic direction epitaxially grown on top of the α -quartz layer. (e) EELS atomic-resolution chemical mapping of Mn, Sr and Ba elements of a BSMO nanowire along the [001] crystallographic direction

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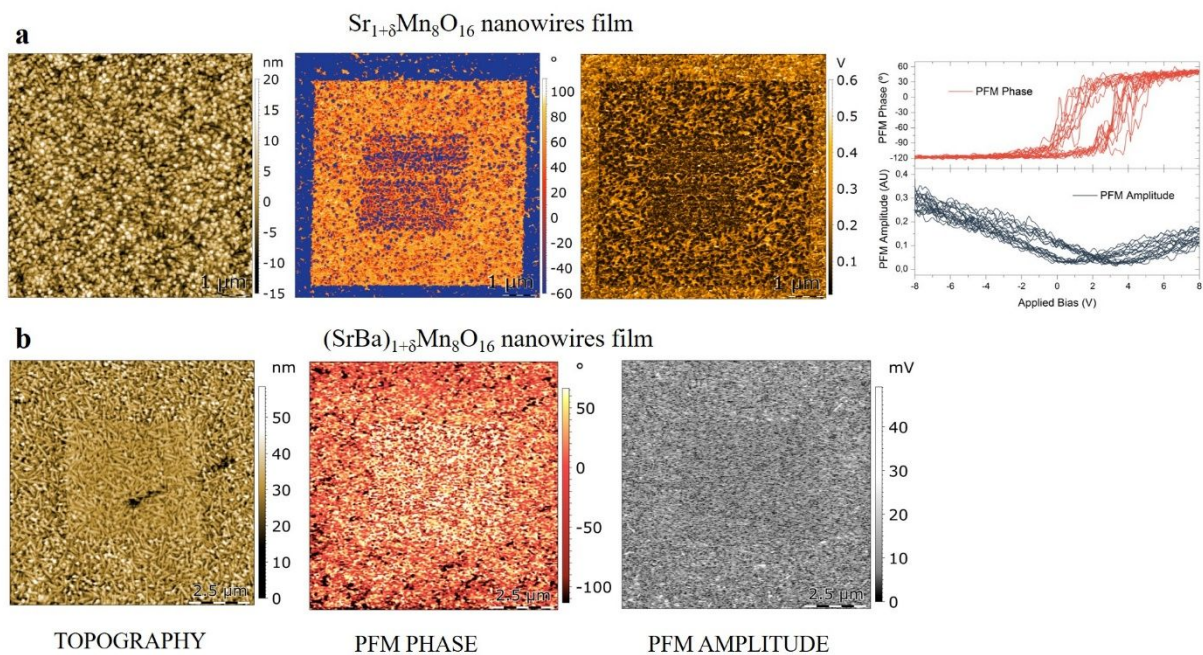
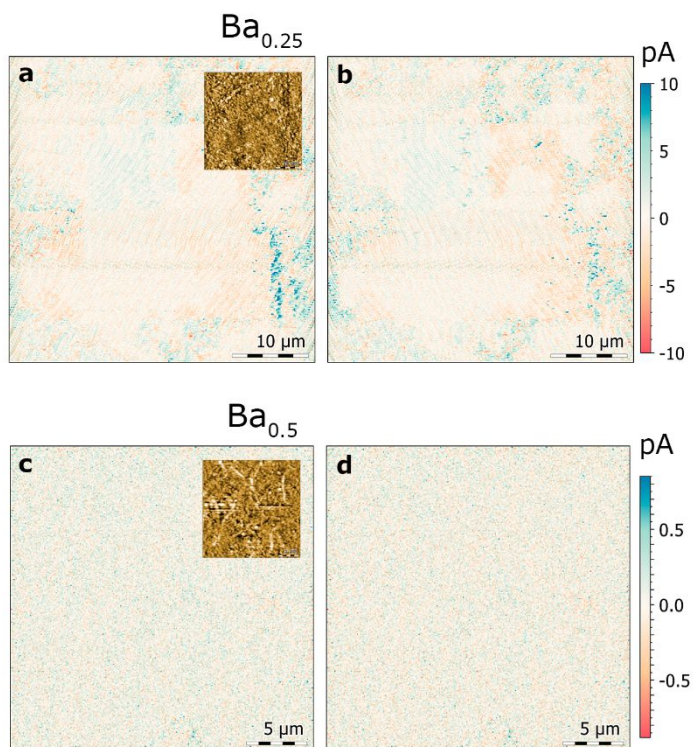


Figure S8. Comparative PFM study between the isostructural BSMO and the SMO hollandite nanowire film. (a) Topographic AFM image, VPFM Phase and VPFM amplitude signals respectively confirming the switching of the SMO nanowire film using a bias of ± 20 VDV due to the ferroelectric nature of this nanowires. (b) Topographic AFM image, VPFM-Phase and VPFM-Amplitude signals of the Barium doped SMO nanowire film respectively that show no differences on the contrast due to a ferroelectricity free behavior.



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Figure S9. DPFM measurements Matrix of the Ba dope SMO samples. DPFM-Si (a) and DPMF-So (b) of a 0.25 Ba sample, with topography AFM image as insert. Both images show a similar contrast, meaning only leakage current is found in the sample and there is no ferroelectric response pattern. DPFM-Si (a) and DPMF-So (b) of a 0.5 Ba sample, for this case the leakage current is in the detection level of our amplifier, while there is still no ferroelectric response.

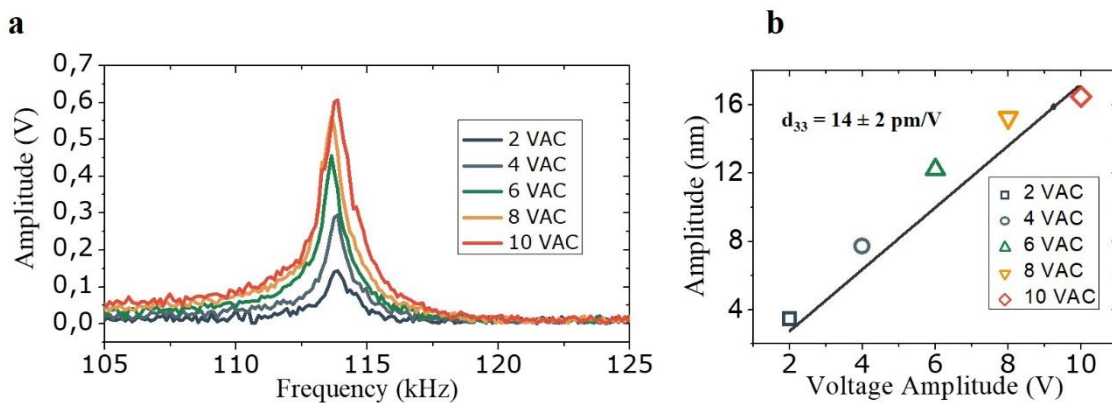


Figure S10. Measurement of d_{33} piezoelectric coefficient of SMO nanowire film by using PFM study. (a) PFM measure at different voltages of a SMO nanowire film. (b) The data shows a linear increase of the PFM resonant frequency amplitude with an increase of the applied AC bias, confirming the piezoelectric functionality of a SMO nanowire film. Importantly, this indirect measure gives a similar value to that of DPFM direct method.

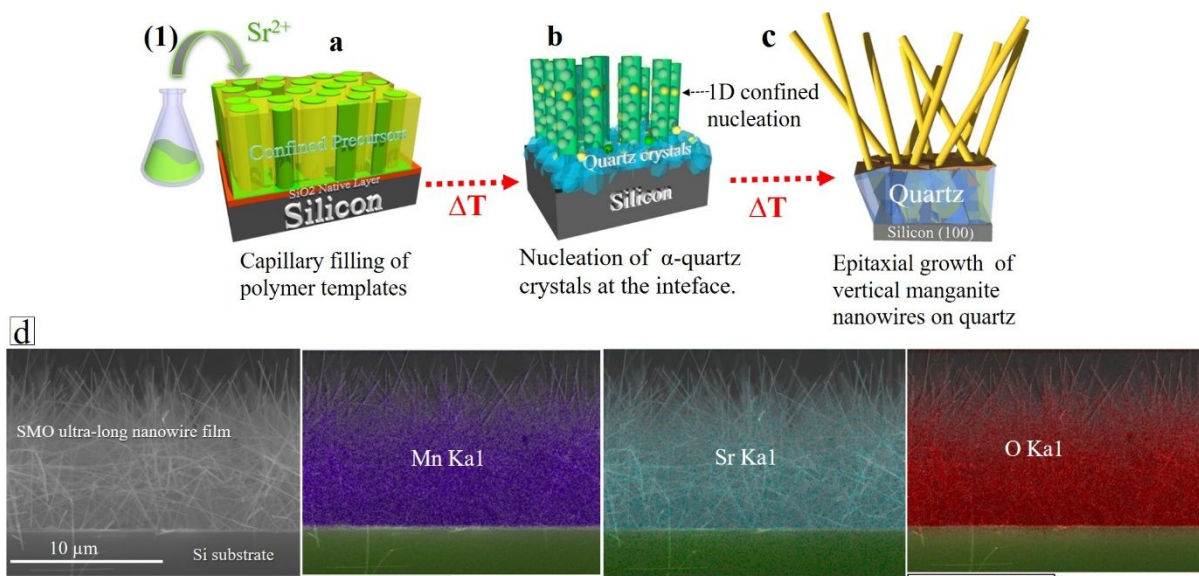


Figure S11. Growth mechanism and synthesis method of SMO ultra-long vertical nanowire thin film on silicon Si (100) substrate. Schematics representing the different steps growth of ultra-long vertical

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epitaxial SMO nanowire i.e. (a) a first stage where a nanoporous polymer template is deposited on Si substrate filled with the chemical precursor solution containing Sr^{2+} melting agents and Mn salt. (b) 1D-confined nucleation in high aspect ratio nanopores of oxide nanowires seeds and first devitrification and nucleation of disoriented quartz crystals at the silicon interface. (c) α -quartz film formation at higher temperatures (800 °C), allowing the epitaxial stabilization of oxide nanowires^[3]. (d) Cross-sectional FEG-SEM image of vertical ultralong SMO nanowire film grown on silicon substrate together with the chemical analysis of Mn, Sr and O element.

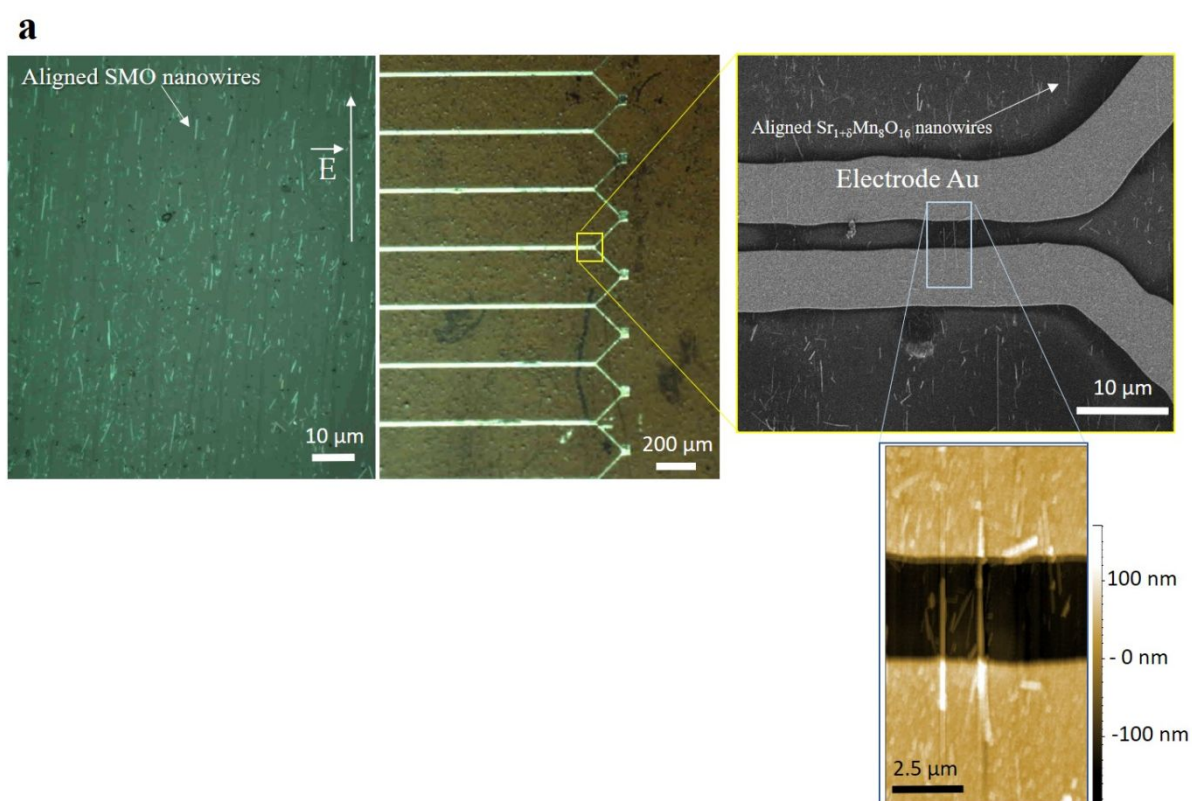


Figure S12. Transfer, alignment and contact of single SMO ultra-long nanowires on flexible Kapton substrate (optical, SEM and AFM topographic images respectively).

References

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